

# EFFICIENCY

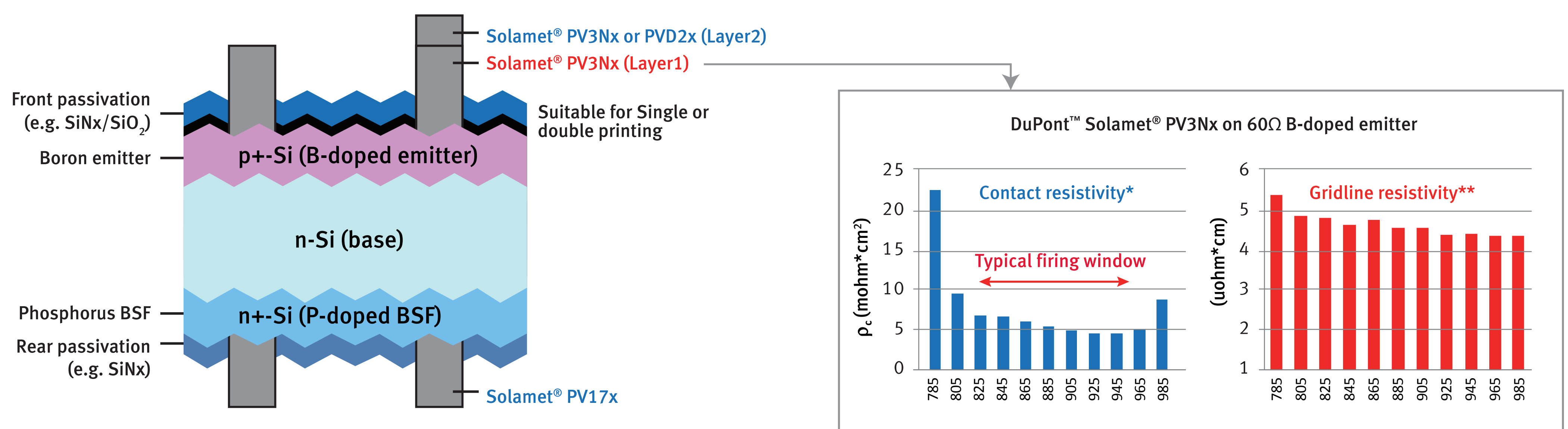
## PHOTOVOLTAIC METALLIZATIONS

On target to boost cell efficiency to 22% in 2015

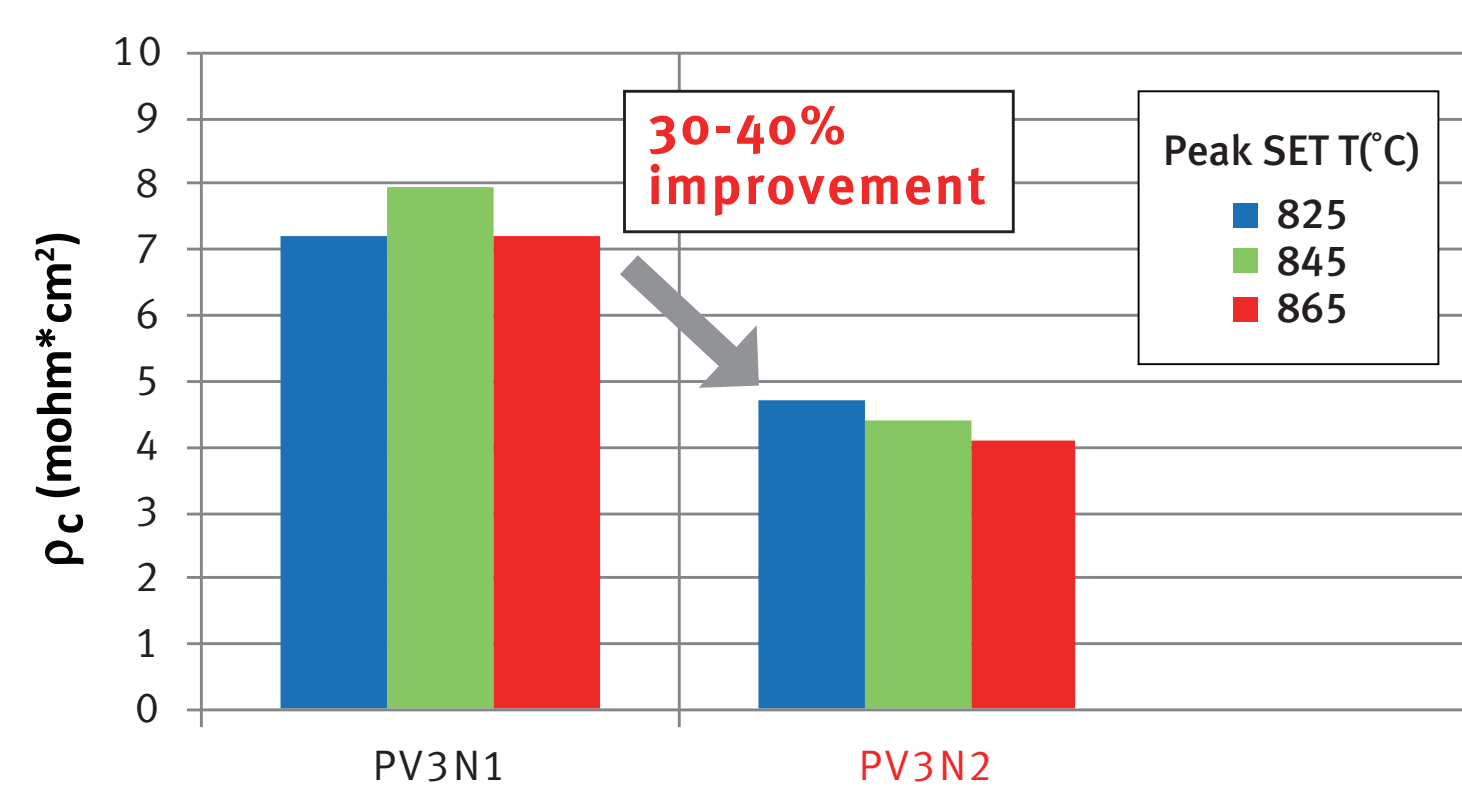
### DuPont™ Solamet® PV3Nx silver/aluminum paste for p-type emitter

- Fineline printability (for gridlines with screen printing)
- Fire-through passivation layer
- Low contact resistivity on B-doped emitter layer
- Low gridline resistivity (high conductivity)
- Co-fireable with rear side contacts
- Good solderability and adhesion

### DuPont™ Solamet® complete metallization package for higher efficiency



### Contact resistivity on B-doped emitter\*



- The new generation Solamet® PV3N2 provides 30-40% better contact resistivity on B-doped emitter compared to Solamet® PV3N1.

\* Measured by TLM.

\*\* R<sub>gl</sub> measured on fired-through contacts. Apparent values calculated assuming uniform line width and height. Crosssectional areas of fired gridlines measured using confocal microscope.